



Irradiations at the INFN-LABEC facility in Florence

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DEFEL

 ELectrostatic DEFlector (DEFlettore ELecttrostatico): the chopped beam line of the Tandem accelerator at INFN-LABEC



Capabilities of the DEFEL beam line

• Pulsed bunches of:

- Duoplasmatron: p (and α)
- Cs-ion sputtering source: p, Li, C, O, Si, Ti, Fe, I

• Energy:

- 1÷6 MeV for protons; 1÷few tens MeV (heavier ions)
- Bunch frequency: up to ~10kHz
- Average ion multiplicity: hundreds particles and more



From continuous to pulsed beam



Ions are deflected from the beam line axis for most of the time (PreDeflector) For time windows of ~ $1\mu s$, ions are allowed to enter the main Deflector

From a continuous to a pulsed beam





11.235 MeV O³⁺ lons



1 MeV protons



Few examples - II



B00

600

(a)

12

The role of the final slits S3

Aperture of slits on y axis \rightarrow

- number of transmitted ions per pulse (it also depends on beam current – once voltage steps, deflector plates length and deflector-to-slits distance are fixed)
- spatial resolution
- Aperture of slits on x axis \rightarrow
 - spatial resolution
- Tipically, 4-independent sectro slits (by Fischer Gmbh) \rightarrow
 - 30-50 μm spatial resolution
 - ~50 μm uncertainty on aperture size
 - \rightarrow Not suitable for precision applications!

Our new slits



- Aperture formed by 4 independent blades
- 30 mm x 30 mm maximum size
- 1 µm resolution
- Designed for high vacuum applications
- Tungsten carbide blades with a 0.5° knife-edge

How to look at the beam

• Typical devices:

- Beam profile monitor
- Luminescent quartz
- downstream the final slits, <u>transmitted beam intensity too low</u>
 Need of a new visualisation

system



The Aptina camera

- 752 x 480 pixels
- Pixel dimensions 6x6 µm
- Programmable through serial interface
- Images acquired using services added to Linux kernel



(MT9V034)

Here is the beam

Slits aperture 1mm x 400 μ m



Here is the beam

Slits aperture 200 x 200 μm



Here is the beam



A new sensor (Aptina, 5M pixels, 2x2 μ m pixel size) is going to be tested...

10 MeV Si implantation in diamond

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State of charge = Si^{3+}
Energies = 8 - 11 MeV
Probe size = 0.2 to 1 mm wide (x and y)
Implantation times ranging from 100 µs (pulsed) to 1 h (continuum)
Fluences = \sim 10^9 - \sim 10^{16} cm<sup>-2</sup>
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Results







5x5 mm²



applications

energy losses and straggling

 N. Taccetti, et al., The pulsed beam facility at the 3MV Van de Graaff accelerator in Florence: overview and examples of applications, Nucl.Instr. & Meth.B 188 (2002), 255

Characterization of detectors

- L. Carraresi, et al., Pulsed Proton Beams as a Diagnostic Tool for the Characterization of Semiconductor Detectors at High Charge Densities. IEEE Nuclear Science Symposium Conference Records (2010), 737
- A. Castoldi, et al., Characterization and diagnostics of fast X-ray Imaging detectors for Xray free electron sources, Proc. of SPIE 8078 (2001), 80780P-1
- A. Castoldi, et al., Mapping of the response function of DePFET-based pixel sensors at different levels of charge injection, IEEE Nuclear Science Symposium Conference Records (2011), 1747
- P.G. Bizzeti, et al., Response of CdWO4 crystal scintillator for few MeV ions and low energy electrons, Nucl.Instr. & Meth. A 696 (2012), 144
- V.I. Tretyak, Semi-empirical Calculation of Quenching Factors for Ions in Scintillators, Astroparticle Physics 33 (2010) 40

Time resolved ion beam induced luminescence

C. Czelusniak, PhD Thesis, ongoing





The set-up for ultra-low intensity measurements

Refractive index control

- 2 and 3 MeV proton implantation in the low damage regime
- fluences (Φ= 10¹³ 10¹⁷ cm⁻²) measured at the Florence microbeam
- refractive index variation OPD =(n-n₀) of implanted diamond measured at the Florence INOA





Experimental data: OPD vs. Fluence



Diamond studies at LABEC

PRL 105, 233903 (2010)

PHYSICAL REVIEW LETTERS

week ending 3 DECEMBER 2010

> DIAMOND RELATED MATERIALS

Evidence of Light Guiding in Ion-Implanted Diamond

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Diamond & Related Materials 19 (2010) 428-431

Contents lists available at ScienceDirect

Diamond & Related Materials

journal homepage: www.elsevier.com/locate/diamond

Controlled variation of the refractive index in ion-damaged diamond

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IBIC study of a CdS/CdTe solar cell





IBIC study of a CdS/CdTe solar cell

- •3 MeV He ions
- the **set-up** for beam current control allowed an easy and fast intensity reduction down to **10**³ particles per second injected directly into the solar cell
- charge collection efficiency (CCE) maps show inhomogeneous response due to the polycrystalline nature of the CdTe bulk material



Pulse height



radiation resistance

- average pulse height decrement of 20% for fluences up to 2.10¹⁰ alpha/cm²
- maps show non-uniform decrease of CCE: large grains with higher efficiencies more sensitive to radiation damage



Contents lists available at ScienceDirect

Nuclear Instruments and Methods in Physics Research B

journal homepage: www.elsevier.com/locate/nimb

IBIC analysis of CdTe/CdS solar cells

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